



Patent Application No. 10/696,254
Customer Number: 42717

IPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Hui Lin Chang	§	Docket No.:	24061.36
		§		(TSMC2002-0939)
Serial No.:	10/696,254	§		
		§	Examiner:	Fazli Erdem
Filing Date:	October 29, 2003	§		
		§	Art Unit:	2826
For:	Insulating Layer Having Decreased	§		
	Dielectric Constant and Increased	§	Conf. No.:	7076
	Hardness	§		

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop: Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450


Dear Sir:

In response to the Office Action mailed August 26, 2004, applicant hereby elects, Group I, Claims 10-25, which is drawn to a semiconductor device.

Applicant's election is made with traverse on the grounds that the embodiments delineated by the examiner are not patentably distinct and therefore constitute a single invention concept.

An early action on the merits is respectfully requested.

Respectfully submitted,


David M. O'Dell
Reg. No. 42,044

Date: 9-27-04

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CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop: Amendment, Commissioner For Patents, PO Box 1450, Alexandria, VA 22313-1450 on the date below.

Bonnie Boyle
Name

9-27-04
Date